Docket No.: 060188-0751 PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Yoshiharu HIDAKA, et al. ¥

Application No.: 10/754,518

Filed: January 12, 2004

Customer Number: 20277

Confirmation Number: 8259

Group Art Unit: 2814

Examiner: Thao X. Le

For: SEMICONDUCTOR SUBSTRATE, METHOD FOR FABRICATING THE SAME, AND

METHOD FOR FABRICATING SEMICONDUCTOR DEVICE

## **INFORMATION DISCLOSURE STATEMENT**

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

This Information Disclosure Statement is being filed more than three months after the U.S. filing date and after the mailing date of a Final Rejection or Notice of Allowance, but before payment of the Issue Fee.

## REQUEST TO CONSIDER REFERENCES AFTER CLOSE OF PROSECUTION AND BEFORE PAYMENT OF ISSUE FEE

The undersigned hereby requests consideration and entry of this Information Disclosure

Statement and accompanying references under 37 CFR 1.97(d).

01/11/2006 JADDO1 00000012 500417 10754518

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Please charge the processing fee under 1.17(p) of \$180.00 to Deposit Account 500417.

10/754,518

**CERTIFICATION PARAGRAPH** 

The undersigned certifies that each item of information contained in this Information

Disclosure Statement was first cited in a communication from a foreign patent office in a

counterpart foreign application not more than three months prior to the filing of this Information

Disclosure Statement as described in 37 CFR 1.97(e)(1).

Each non-English language reference was cited in a corresponding foreign application

office action and its relevance discussed therein. A copy of the foreign office action, is attached

for the Examiner's information.

Please charge any shortage in fees due in connection with the filing of this paper,

including extension of time fees, to Deposit Account 500417 and please credit any excess fees to

such deposit account.

Respectfully submitted,

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Date: January 9, 2006

Please recognize our Customer No. 20277 as our correspondence address.

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January 12, 2004 2814 U.S. PATENT DOCUMENTS										
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<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.